Steps Toward Accurate Large Area Analyzes of Genesis Solar Wind Samples: Evaluation of Surface Cleaning Methods Using Total Reflection X-ray Fluorescence Spectrometry

Martina Schmeling*1, Donald S. Burnett 2, Amy J.G. Jurewicz3, Igor V. Veryovkin4
1Loyola University Chicago, Chicago, Illinois 60660
2California Institute of Technology, Pasadena, California 91125
3Arizona State University, Tempe, Arizona 85287
4Argonne National Laboratory, Argonne, Illinois 60439

Abstract
Total reflection X-ray fluorescence spectrometry (TXRF) was used to analyze residual surface contamination on Genesis solar wind samples and to evaluate different cleaning methods. The Genesis mission collected solar wind during a period of 854 days by embedding the charged particles into collectors made of various ultra clean materials such as silicon, sapphire and silicon-on-sapphire. The sample return capsule unexpectedly crashed on return to Earth fracturing the collectors and exposing them to the desert soil of the landing side. The ubiquitous contaminants are separated from the atoms of solar wind by only 5-15 nm, presenting significant challenges for solar wind analysis as well as the development of cleaning techniques.

Currently, an ultrapure water and ozone UV radiation treatment is routinely applied to the collectors by the curatorial team at NASA’s Johnson Space Center. Additional cleaning steps involving various forms of acid treatment and/or carbon dioxide snow treatment are being evaluated as well. To gauge the suitability of the cleaning method, two samples were analyzed following cleaning by lab-based TXRF. The analysis comprised of an overview and a crude manual mapping of the samples by orienting them with respect to the incident X-ray beam in such way that different regions were covered. The results showed that cleaning with concentrated hydrochloric acid and a combination of hydrochloric acid and hydrofluoric acid decreased persistent inorganic contaminants substantially on one sample. Application of carbon dioxide snow for surface cleaning tested on the other sample appears to be effective in removing one persistent Genesis contaminant, namely germanium. Unfortunately, the TXRF analysis results of the second sample were impacted by relatively high background contamination. This was mostly due to the relatively small sample size and that the solar wind collector was already mounted with silver glue for resonance ion mass spectrometry (RIMS) on an aluminum stub. Further studies are planned to eliminate this problem. In an effort to identify the location of very persistent contaminants, selected samples were also subjected to environmental scanning electron microscopy. The results showed excellent agreement with TXRF analysis.

Introduction
The NASA Genesis mission is the first mission returning solar material to Earth for laboratory analysis after the Apollo program (Burnett et al., 2003). Solar wind (SW) was collected by passively exposing ultrapure materials such as silicon and sapphire (Al2O3), mounted on a small spacecraft, to the charged particles (Jurewicz et al., 2003). The collection took place at at Lagrange 1 (L1) point, where gravities of Sun and Earth are equal, for a duration of 854 days (Reisenberg et al., 2005). The space craft returned to Earth on September 8, 2004 with an unexpected crash landing in the Utah desert. The impact not only fractured the collectors...
This document was presented at the Denver X-ray Conference (DXC) on Applications of X-ray Analysis.

Sponsored by the International Centre for Diffraction Data (ICDD).

This document is provided by ICDD in cooperation with the authors and presenters of the DXC for the express purpose of educating the scientific community.

*All copyrights for the document are retained by ICDD.*

Usage is restricted for the purposes of education and scientific research.

**DXC Website**  
− [www.dxcicdd.com](http://www.dxcicdd.com)

**ICDD Website**  
- [www.icdd.com](http://www.icdd.com)
into small irregular pieces, but also broke the return capsule open exposing the collectors to the desert environment. As a result samples were contaminated and have to be cleaned individually before most analyses of solar wind material can be carried out. The contamination varies from sample to sample, but consists primarily of two types: an organic silicone-like film acquired in flight and particulates from the hard landing. Different surface cleaning procedures for removal of both types of contaminations were and are still being developed to enable analysis of minor solar wind elements prominent also in the contamination (Allton et al., 2000, Calaway et al., 2007, 2009; Huang et al., 2006, 2008, Schmeling et al., 2011, Sestak et al., 2006).

Each sample has to be checked after cleaning to decide whether removal of contaminants was successful and to guide what, if any additional cleaning steps are required. Analysis methods employed for post-cleaning control have to be surface sensitive and non-destructive in order to avoid additional contamination. They also have to be fast and multi-element capable to accommodate the large number of samples. Bench-top total reflection X-ray fluorescence spectrometry (TXRF) offers all these features as it is a non-destructive, surface sensitive analysis method with detection limits in the lower $10^{11}$ atoms/cm$^2$ to $10^9$atoms/cm$^2$ range. (Klockenkaemper, 1997; Pahlke et al., 2001; Schmeling, 2004; Schmeling et al., 2011; Sekowski et al., 2008; Shaffner, 2000; Streli et al., 1999; West et al., 2010; Wobrauschek, 1998 and 2007).

To date a total of 18 different Genesis samples consisting of silicon, silicon on sapphire and sapphire were analyzed using bench top TXRF after applying different methods of surface cleaning. Two samples treated by very different surface cleaning methods were selected for this study to demonstrate the capability of bench-top TXRF and also to highlight the challenges faced with this type of sample. The results indicate that each material is unique and requires a specific cleaning approach, which often has to be adapted for Genesis samples.

Instrumentation and Methods

Most sample analysis was carried out with a PicoTax® TXRF spectrometer utilizing a fine focus X-ray tube with Mo target (40 kV and 1000 μA operating conditions). Some of the samples were analyzed with the newly acquired S2 Pico Fox® TXRF spectrometer equipped with a micro focus X-ray tube with Mo target (40 kV, 600 μA) and a curved multilayer, focusing the X-ray beam on the sample. Both instruments are equipped with a silicon drift detector and were manufactured by Bruker AXS, Berlin, Germany. The sample spot size for the Pico Tax® instrument is about 2 mm (width) x 5 mm (length) and for the S2 PicoFox® instrument 0.1 mm (width) x 5 mm (length).

Since both instruments use vertical loading of the sample, they were tilted 90 degrees and supported in a frame structure to allow for horizontal loading of the Genesis samples. Special polycarbonate templates were made having an area large enough for the Genesis sample to be placed into a pocket of appropriate depth milled out of the material to make a flush surface of sample and carrier. Figure 1 shows a template together with a sample. The templates were cleaned by ultrasonication in soapy water, then rinsed with 18MOhm water and checked for contamination before each analysis. The Genesis sample was then placed carefully into the cleaned template using PTFE tweezers in a class 100 clean bench and transferred to the TXRF instrument in a closed container to avoid contamination during transport. TXRF analysis of the samples was carried out with counting times of 7200 s for PicoTax® and 2000 s for S2 PicoFox® instrument respectively. Higher sensitivity permitted for shorter measurement times with S2 PicoFox®. Counting times were adjusted when needed in order to determine
contaminations present. The detection limits (in atoms/cm\(^2\)) for a counting time of 7200 seconds for both instruments are shown in table 1.

All samples were analyzed by TXRF after being cleaned with ultrapure water (UPW) and some samples were cleaned with UV Ozone at Johnson Space Center, which removes many of the larger particulates and organic materials, respectively (Allton et al., 2007, Calaway et al., 2007, 2009). Two approaches for cleaning were then investigated: 1) Acid cleaning for sample sapphire (Al\(_2\)O\(_3\)) 50719 and 2) CO\(_2\) snow cleaning for sample silicon 60758. For 1) Sample 50719 was subjected to a 6M hydrochloric acid cleaning cycle analyzed by TXRF and then underwent a second more rigorous cleaning step involving hydrofluoric (1:5) and hydrochloric acid (6M). In case 2) sample 60578 was placed in a CO\(_2\) snow cleaning apparatus based on the system manufactured by Applied Surface Technologies (New Providence, NJ; high purity unit K4-10, http://www.co2clean.com). This sample was placed in a sealed chamber, which was purged with dry nitrogen for 2 hours prior to raster scanning the surface of the sample with a CO\(_2\) snow jet for about 30 minutes. TXRF analysis was carried out before and after CO\(_2\) cleaning. The acid treated sample was also investigated by scanning electron microscopy (FEI XL 30) to locate and identify remnant particulate contamination.

Figure 1: A NASA Genesis solar wind sample (silicon on sapphire) as placed in a polycarbonate analysis template, specifically made for this purpose.

Table 1: Detection limits for selected elements measured with PicoTax (blue) and PicoTax (green). Counting time 7200 seconds.

<table>
<thead>
<tr>
<th>Element</th>
<th>PicoTax [atoms/cm(^2)]</th>
<th>PicoFox [atoms/cm(^2)]</th>
</tr>
</thead>
<tbody>
<tr>
<td>K</td>
<td>9x10(^{11})</td>
<td>2x10(^{11})</td>
</tr>
<tr>
<td>Ca</td>
<td>6x10(^{11})</td>
<td>1x10(^{11})</td>
</tr>
<tr>
<td>Cr</td>
<td>2x10(^{11})</td>
<td>3x10(^{10})</td>
</tr>
<tr>
<td>Mn</td>
<td>2x10(^{11})</td>
<td>4x10(^{10})</td>
</tr>
<tr>
<td>Fe</td>
<td>1x10(^{11})</td>
<td>2x10(^{10})</td>
</tr>
<tr>
<td>Ni</td>
<td>8x10(^{10})</td>
<td>1x10(^{10})</td>
</tr>
<tr>
<td>Zn</td>
<td>5x10(^{10})</td>
<td>9x10(^{9})</td>
</tr>
<tr>
<td>Ga</td>
<td>7x10(^{10})</td>
<td>1x10(^{10})</td>
</tr>
<tr>
<td>Ge</td>
<td>4x10(^{10})</td>
<td>6x10(^{9})</td>
</tr>
<tr>
<td>Rb</td>
<td>4x10(^{10})</td>
<td>8x10(^{9})</td>
</tr>
<tr>
<td>Sr</td>
<td>4x10(^{10})</td>
<td>6x10(^{9})</td>
</tr>
<tr>
<td>Pb</td>
<td>1x10(^{10})</td>
<td>4x10(^{9})</td>
</tr>
</tbody>
</table>
**Results**

1. Acid Cleaning - NASA Genesis Solar Wind Sample Sapphire 50719

NASA Genesis sample sapphire (Al₂O₃) 50719 underwent three cleaning steps as described under 1) in the experimental section with subsequent analysis by TXRF. Figure 2 shows TXRF analysis results using the PicoTax® instrument following each cleaning step. The green spectrum shows the results obtained after ultrapure water and UV/O₃ treatment, the blue spectrum was recorded after 6 M HCl cleaning and the red spectrum shows the results after additional cleaning with 1:5 HF:H₂O and 6 M HCl. Clearly noticeable is the difference in background scattering for the spectra before and after the first acid cleaning, especially pronounced in the lower energy range. The elevated background for the green spectrum (before acid cleaning) most likely indicates the presence of the film-like organic surface contamination acquired in flight, which appears to be removed by 6 M hydrochloric acid treatment. The large peak remaining after 6 M HCl and somewhat reduced after second acid cleaning with HF and HCl corresponds to germanium. Some of the collectors were made of high purity germanium and were pulverized during the crash. As a result most collector fragments show germanium contamination to a certain degree. Inspection using scanning electron microscopy of the same area analyzed by TXRF yields also germanium as contaminant. An estimation of contamination remaining after each analysis step was attempted. For this the count rate of the element(s) measured on the sample surface was compared to the count rate of a standard containing known concentrations of the element in the same order of magnitude than the sample. The counting time was the same as the sample. Table 2 shows the rough estimates. It is important to keep in mind that these rough estimates are indicating only the order of magnitude of contamination and not the exact amount.

![Figure 2: Spectra obtained after different cleaning steps for sample Al₂O₃ 50719. The green spectrum was acquired after routine cleaning with UPW and UV/O₃ (Allton et al., 2007), the blue spectrum was measured after cleaning the sample with 6 M HCl and the red spectrum corresponds to the sample after an additional cleaning step with 1:5 HF:H₂O and 6 M HCl.](image)
Table 2: Estimated concentrations of remaining surface contaminants after each cleaning step.

2. CO₂ Snow Cleaning - NASA Genesis Solar Wind Sample Silicon 60758

Another Genesis sample, 60758, made of silicon, was subjected to a different cleaning approach using CO₂ snow as described in the experimental section. CO₂ snow is widely used as a cleaning step in the semiconductor industry. CO₂ cleaning is gentle and fast and does not attack the material itself, but only removes particles located at the surface of the substrate. The sample was already mounted on a stub for resonance ion mass spectrometry analysis (RIMS) and special polycarbonate templates were made accounting for this. The templates had markers to ensure that the sample was loaded in the same position into the TXRF spectrometer each time, before and after cleaning. The sample was analyzed with both the PicoTax® and the S2PicoFox® instruments before and after cleaning with CO₂ snow. The older PicoTax® instrument has a larger analysis spot with 5 mm length and 2 mm width and thus provides a good overview measurement of the sample. The newer S2 PicoFox® instrument has an analysis spot size of 5 mm in length and 0.1 mm in width, thus making it possible to obtain some crude surface mapping when the sample is moved systematically with respect to the beam. This was achieved by using different templates, which held the sample in different off-set positions from the center of the beam spot. The sample itself was about 5 mm in one direction and about 4 mm in the other direction. Because the sample was already fixed on a stub, sometimes several spectra were necessary to ensure that proper total reflection of the X-ray beam on the sample surface was achieved. Figures 3 and 4 show the results obtained with PicoTax® (Figure 3) and S2 PicoFox® (Figure 4) before and after the CO₂ cleaning step. The initial contamination of the sample is shown as the blue spectrum in Figure 3 and Figure 4. The green spectra in Figure 3 and in Figure 4 show the results after CO₂ cleaning of the sample. It is important to note that the sample was mounted with glue containing mostly silver but also other elements. Possibly the peaks of Fe, Cu, Zn, Pb and Bi originate besides the Ag from the glue as the X-ray beam striking the sample is larger in one direction than the sample itself and might also irradiate the glue and aluminum mount surrounding the sample on all sides. Moreover as the sample is progressively moved away from the center of the irradiated area, more and more of the mount together with the glue and less sample is being exposed to the beam accounting for additional peaks. To clarify the source of some of the elements detected we are in the process of measuring the glue itself and compare it to the spectra obtained for sample 60758. The germanium peak (at ~9.8keV) very likely originates from the sample and was noticeably reduced after CO₂ cleaning as seen in both sets of measurements. So far these results seem to indicate that CO₂ snow cleaning might be a good and
gentle alternative to acid cleaning when the contaminants, like in this case Ge, are loosely held at the surface.

Figure 3: Analysis of sample Si 60758 by PicoTax® TXRF spectrometer with spot size 5 mm length and 2 mm width. The blue spectrum shows the sample before CO₂ cleaning whereas the green spectrum shows the sample after CO₂ cleaning.

Figure 4: Analysis of sample Si 60758 by S2 PicoFox® TXRF spectrometer having a spot size of 5 mm length and 0.1 mm width. The blue spectrum shows the sample before CO₂ cleaning and the green one after CO₂ cleaning.

Conclusion

Bench top TXRF spectrometry was used successfully to analyze surface contaminations on NASA Genesis solar wind samples before and after cleaning procedures. Two different cleaning approaches were explored and both appear to be promising. In some cases additional measurements identifying contamination originating from sample treatment (i.e. sample glue for
mounting prior to RIMS analysis) have to be carried out in order to identify the actual remnant Genesis contaminations.

Acknowledgements: The work described was supported by NASA/JPL grant 1369203 and NASA grant NNX10AH05G. The work of I.V.V is supported by NASA through grant NNH09AM48I, and by UChicago Argonne, LLC, under contract No. DE-AC02-06CH11357. The authors would like to thank C.E. Tripa for his help in preparing the CO₂ snow cleaned samples.

References


